

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

U.S. Patent No.: 7,273,533
Issue Date: September 25, 2007
Serial No.: 10/717,268
Applicants: Brcka et al.
Title: PLASMA PROCESSING SYSTEM WITH LOCALLY-EFFICIENT
INDUCTIVE PLASMA COUPLING
Attorney Docket: TAZ-248
Confirmation No.: 7396

Cincinnati, Ohio 45202

September 13, 2008

VIA ELECTRONIC FILING

Certificate of Corrections Branch
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

REQUEST FOR CERTIFICATE OF CORRECTION
(37 CFR §§ 1.322(a), 1.323)

It is respectfully requested that a Certificate of Correction be issued for the above-identified patent. The patent contains errors that occurred through the fault of the U.S. Patent and Trademark Office. The patent also contains errors that occurred by Applicants in the specification.

Form PTO/SB/44 outlining the corrections to be made is submitted herewith.

Applicants submit herewith the fee of \$100 due as a result of this request. If any deficiencies or credits are necessary to complete this communication, please apply them to Deposit Account No. 23-3000.

Respectfully submitted,

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UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

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APPLICATION NO.: 10/717,268
ISSUE DATE : September 25, 2007
INVENTOR(S) : Brcka et al.

It is certified that an error appears or errors appear in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Cover page, under the "References Cited" section, "6,685,799 B2* 2/2004 Hooshdaran et al." should read --6,685,799 B2* 2/2004 Davis et al.--
Col. 2, line 31, "torroids," should read --toroids,--.
Col. 2, line 35, "by the present applicant" should read --by the present applicants--.
Col. 2, line 39, "are becoming of increase demand" should read --are becoming of increased demand--.
Col. 2, line 51, "processing of 300 mm wafer." should read --processing of 300 mm wafers.--.
Col. 5, line 4, "low flux channels, are" should read --low flux channels are--.
Col. 8, line 23, "Applicant has proposed" should read --Applicants have proposed--.
Col. 10, line 3, "of the rf power deposited into" should read --of the RF power deposited into--.
Col. 10, line 45, "(FIG. 2O and 2F)" should read --(FIGS. 2D and 2F)--.

MAILING ADDRESS OF SENDER (Please do not use customer number below):

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This collection of information is required by 37 CFR 1.322, 1.323, and 1.324. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. This collection is estimated to take 1.0 hour to complete, including gathering, preparing, and submitting the completed application form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. **SEND TO: Attention Certificate of Corrections Branch, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.**

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